

# Growth and properties of (ultra) nano crystalline diamond

**nanoTUM**

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- Nano-related research at the Technische Universität München:  
more than 50 research groups from  
several faculties and central institutes are  
working on nanoscience and nanotechnology
- Broad range of research topics (theoretical work, fundamental research, applied  
science, technology)
- Many topics/research fields are interdisciplinary

## 2004: start of nanoTUM – TUM Institute for Nanoscience and Nanotechnology

- Coordination of all activities in the field of nanoscience/nanotechnology in one  
virtual institute
- Cross-links to other nano clusters/networks in and around Munich by concomitant  
members in Clusters of Excellence etc.
- Intensive collaboration with partner universities DTU and TU/e

# Chemical vapour deposition (CVD) of diamond

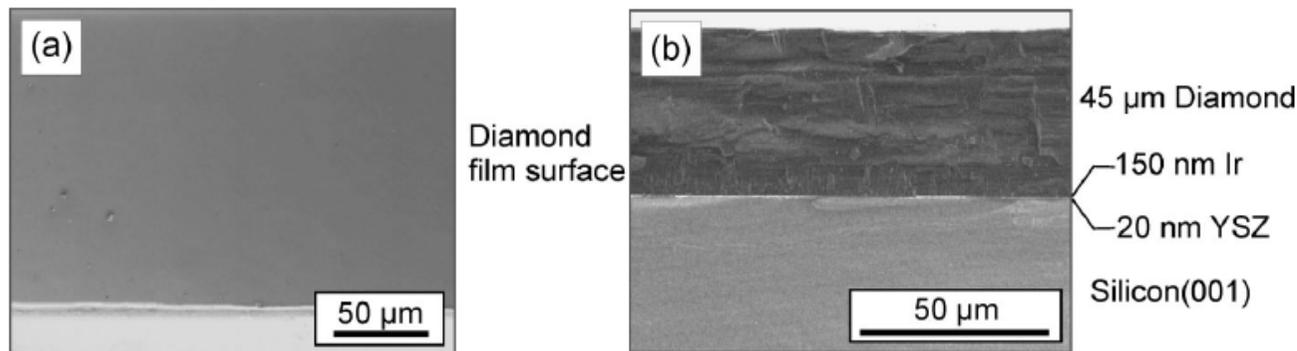
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- Gas mixture of carbon containing gas and hydrogen  
e.g. 1-5% CH<sub>4</sub> in H<sub>2</sub>
- Formation of radicals and atomic hydrogen by plasma or hot filament
- High enough substrate temperature: diamond deposition
- Role of atomic hydrogen:
  - stabilisation of sp<sup>3</sup> carbon phase
  - etching of sp<sup>2</sup> carbon phase
- Deposition on non-diamond substrates:  
pretreatment required to enhance nucleation density
- Morphology: from monocrystalline to (ultra)nanocrystalline

# Monocrystalline CVD diamond films

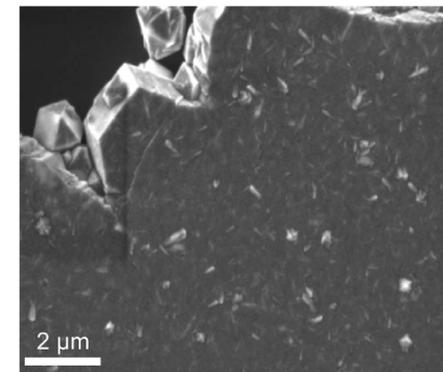
- Homoepitaxy: diamond substrates  
limited by size of substrates
- Heteroepitaxy: bias enhanced nucleation  
Ir/SrTiO<sub>3</sub>/Si(001) (Schreck et al. 2004)  
Ir/YSZ/Si(001), Ir/YSZ/Si(111) (Schreck et al. 2004, 2008)  
up to 4 inch.

Diamond on Ir/YSZ/Si(001)



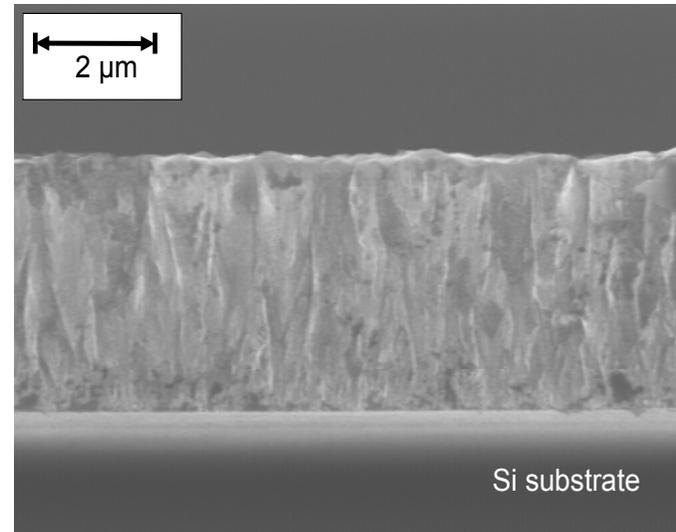
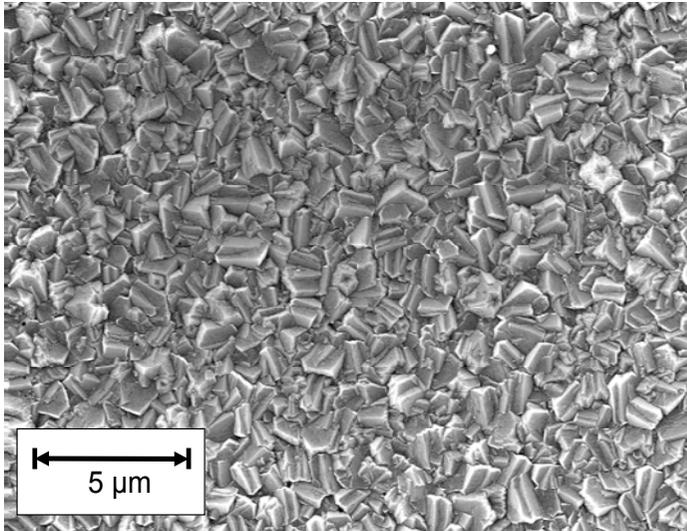
Gsell, Schreck et al. 2004

Diamond on Ir/YSZ/Si(111)



Fischer, Schreck et al. 2008

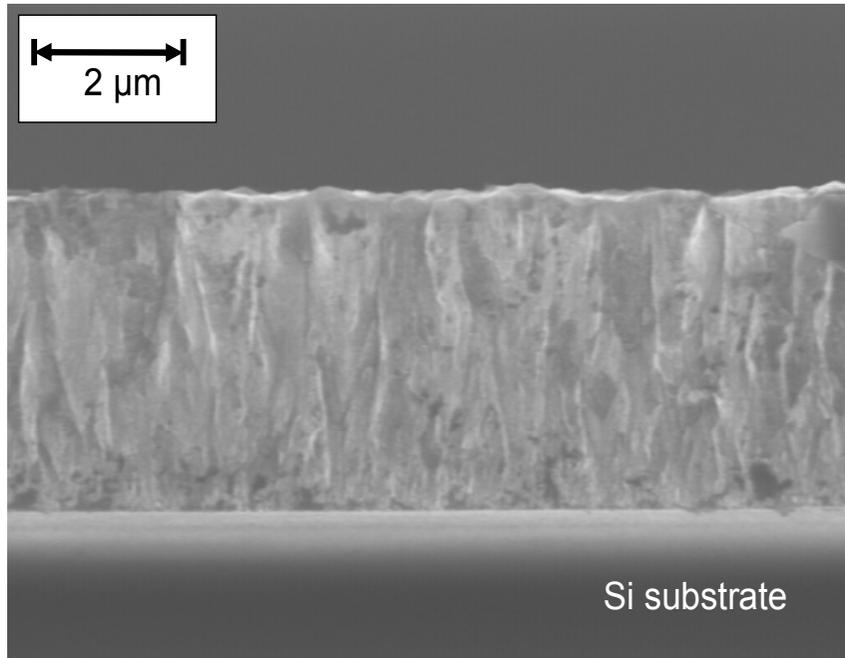
# Polycrystalline CVD diamond films



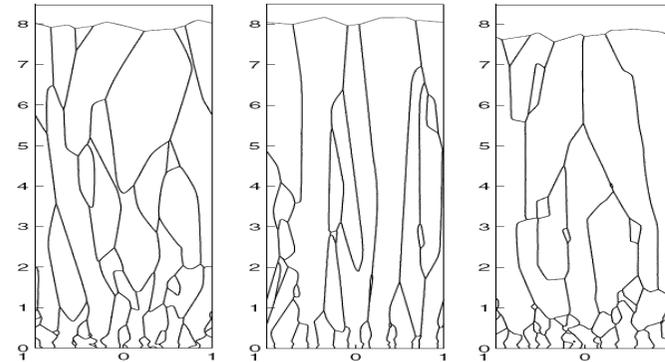
Sternschulte et al. Diamond 2006

- Substrates: Si, SiC, glass, metals (e.g. Ti, Mo, WC) etc
- Columnar growth
- Roughness increases with film thickness

# Polycrystalline diamond (PCD) films: Van der Drift growth model



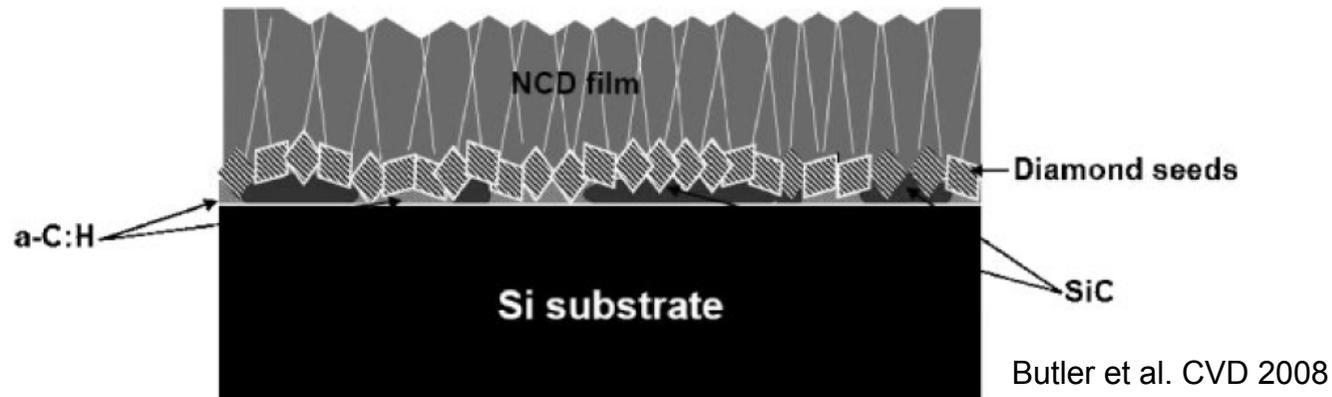
Sternschulte et al. Diamond 2006



Smereka et al. Acta Materialica 2005

- Van der Drift growth model: overgrowth of crystallites
  - ⇒ Development of surface texture depending on fastest growth direction
  - ⇒ Fastest growth direction influenced by growth parameters e.g. by  $\text{CH}_4$  concentration, substrate temperature

# PCD with short deposition times: “pseudo” nanocrystalline diamond films



	low nucleation density thin films	low nucleation density thick films	high nucleation density
low rate of secondary nucleation			

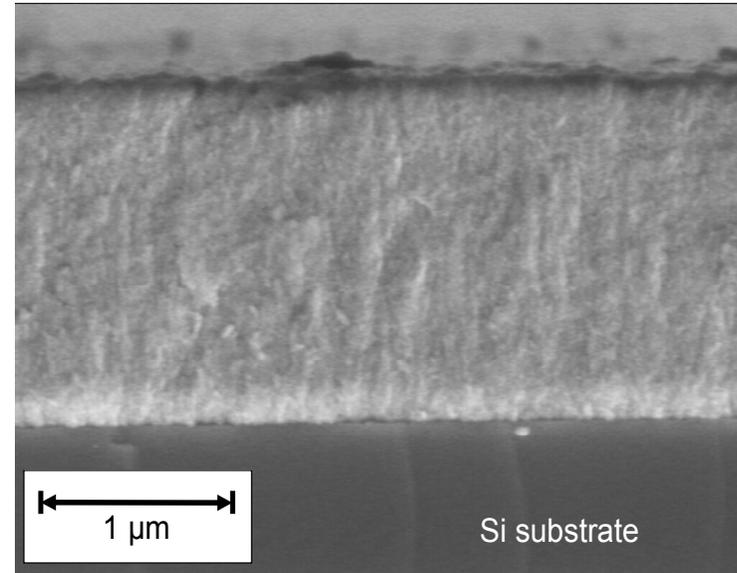
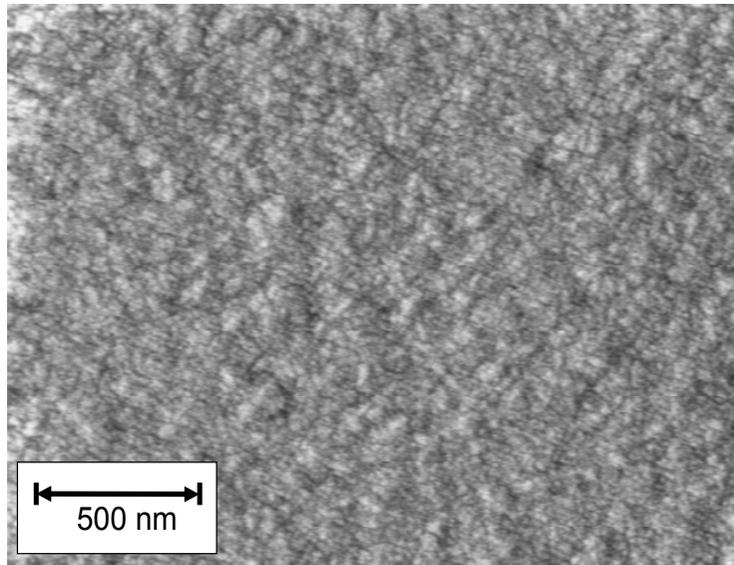
Kulisch et al. phys. stat. sol. (a) 203 (2006) 203

Very high diamond nucleation density on substrate and short deposition times:

⇒ thin fully closed films with small diamond crystallites  
grain size (lateral) up to 100nm

But: Anisotropic properties

# (Ultra) Nanocrystalline CVD diamond films



Sternschulte et al. Diamond 2006

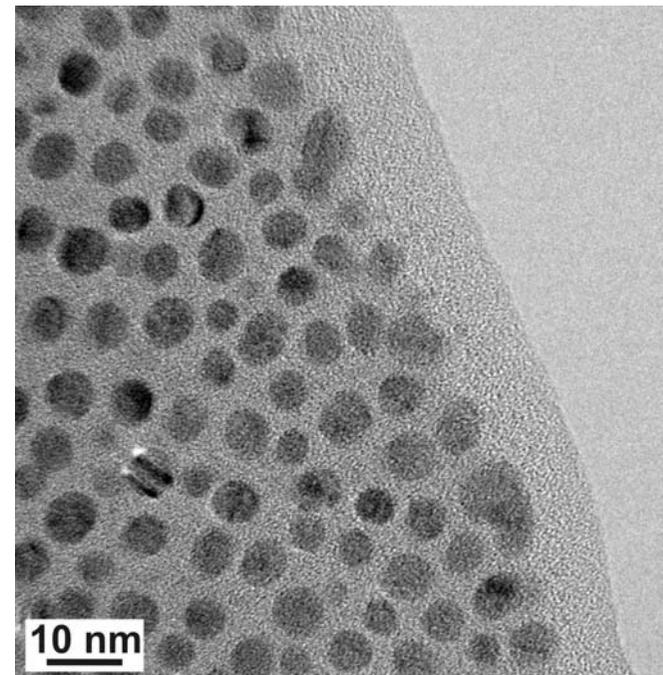
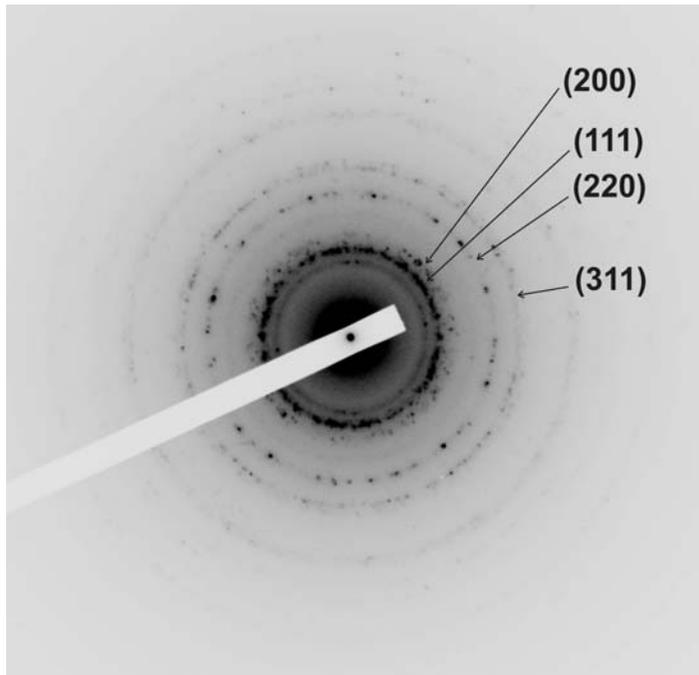
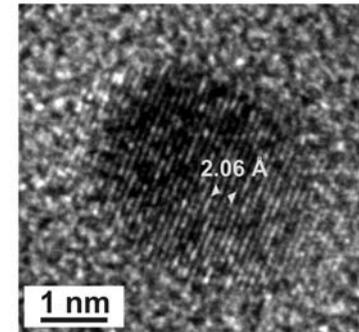
- Fine grained material with structureless cross section
- “Homogeneous” material compared to PCD
- Roughness  $\approx 10\text{-}15\text{nm}$   
independent from film thickness up to several  $\mu\text{m}$
- Different growth mode

# Growth of ultra nano crystalline diamond (UNCD) films

- CVD with oversaturated carbon precursor concentration  
e.g. by replacement of hydrogen gas by Ar or N<sub>2</sub>  
or drastically increased carbon concentration in H<sub>2</sub> gas mixture
  - Other possibility: applied bias voltage during growth process
- ⇒ Generation of high concentrations of defects at the surface
- Defect sites cause formation of twins, nucleation of new crystallites
- ⇒ Extremely high secondary nucleation rate during diamond deposition
- ⇒ small diamond grains
- Ultrananocrystalline diamond (UNCD): diamond grains  $\leq 10\text{nm}$   
Nanocrystalline diamond (NCD): diamond grains  $\approx 10\text{-}100\text{nm}$

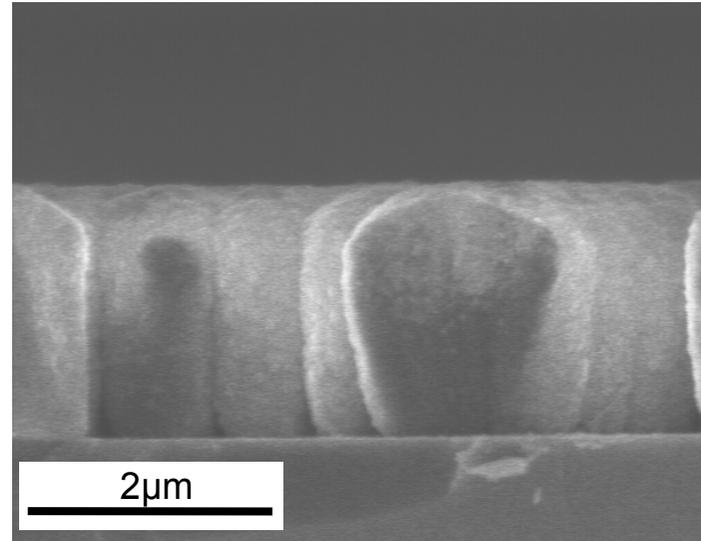
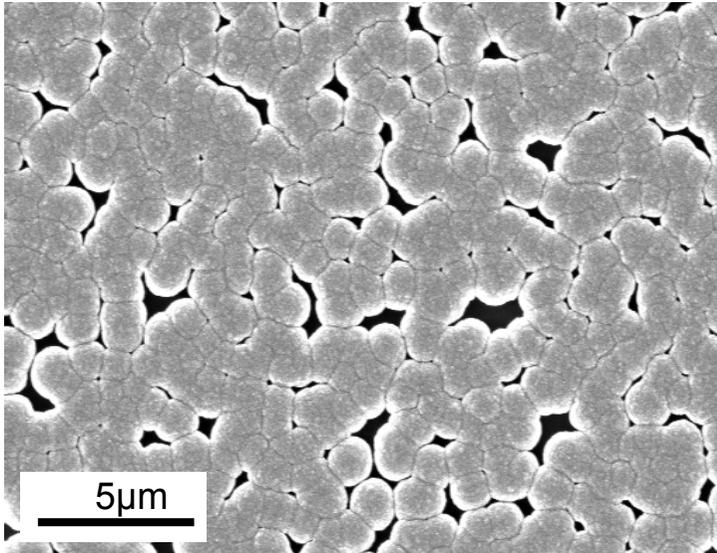
# Structural properties of UNCD films

- Small crystalline diamond grains embedded in amorphous  $sp^2/sp^3$  C:H matrix
  - No preferred orientation: powder like
- ⇒ Model system for amorphous materials



TEM: R. Brescia  
(Uni Augsburg)

# Morphology of UNCD on Si: low nucleation density with $10^8/\text{cm}^2$

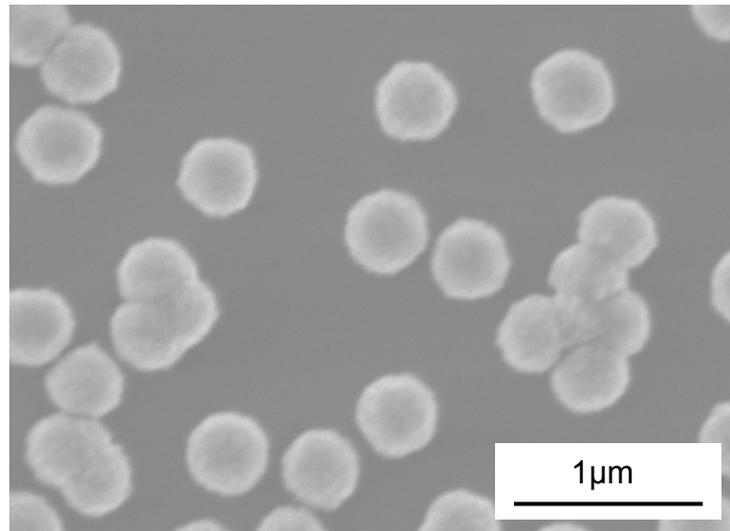


Sternschulte et al., Diamond 2007

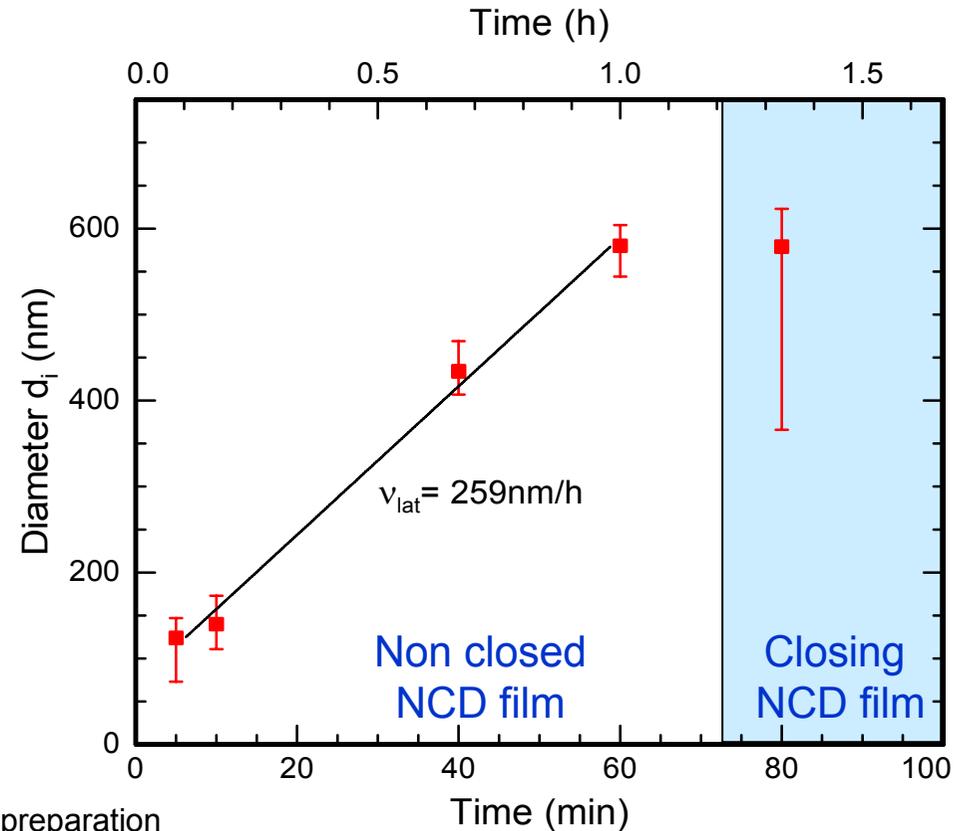
- Rough surface with circular shaped diamond islands
- Each sphere consists of nanocrystalline diamond

# Growth mechanism

SEM: UNCD with  $t_{\text{dep}}=40\text{min}$



Sternschulte et al, in preparation

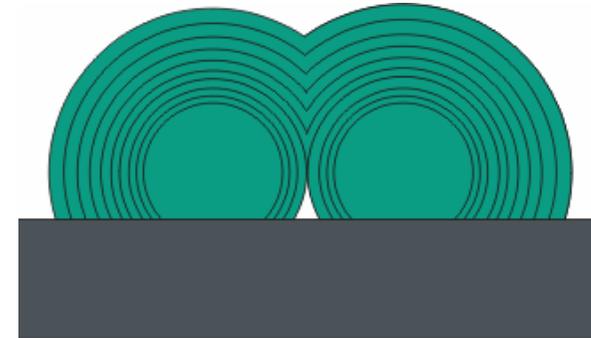


- Diamond island size distribution independent from deposition time  
⇒ no diffusion controlled growth

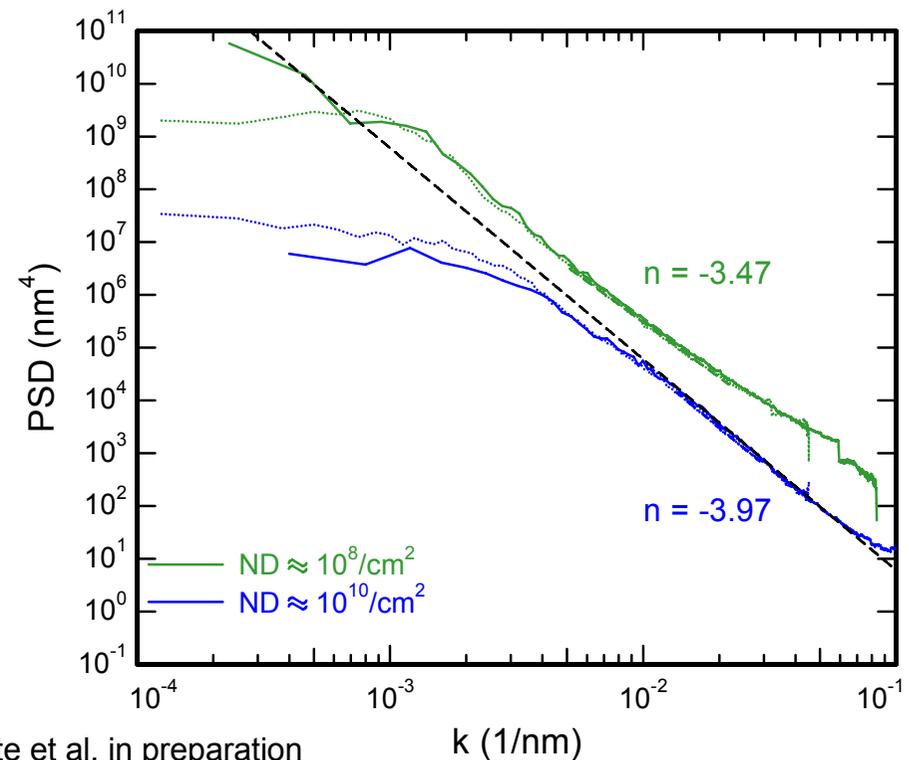
# Growth mechanism

- Growth mechanism:  
growth perpendicular to surface  
(Huygens principle)

⇒ Smoothing via growth and  
coalescence of diamond islands



- From PSD analysis of surface roughness:  
Indication for smoothing effect  
by surface diffusion



# Properties of UNCD and NCD: how large is the influence of the grain boundaries?

- UNCD/NCD consists of diamond nano particles embedded in a matrix

⇒ High fraction of atoms located at grain boundaries:

cubic diamond grain with  $a = 3.6\text{nm}$ : 38% C at surface

$a = 36\text{nm}$ : 3.8 % C at surface

⇒ Small volume fraction of diamond:

grain boundary width 4nm and  $\varnothing_{\text{dia}} = 10\text{nm}$ : 36% of volume is diamond

$\varnothing_{\text{dia}} = 20\text{nm}$ : 58%

$\varnothing_{\text{dia}} = 5\text{nm}$ : 17%

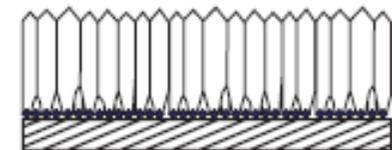
- “Number“ of grain boundaries:

UNCD: grain boundaries in 3D: 10nm grain size  $\Rightarrow 10^{18}/\text{cm}^3$

100nm grain size  $\Rightarrow 10^{15}/\text{cm}^3$

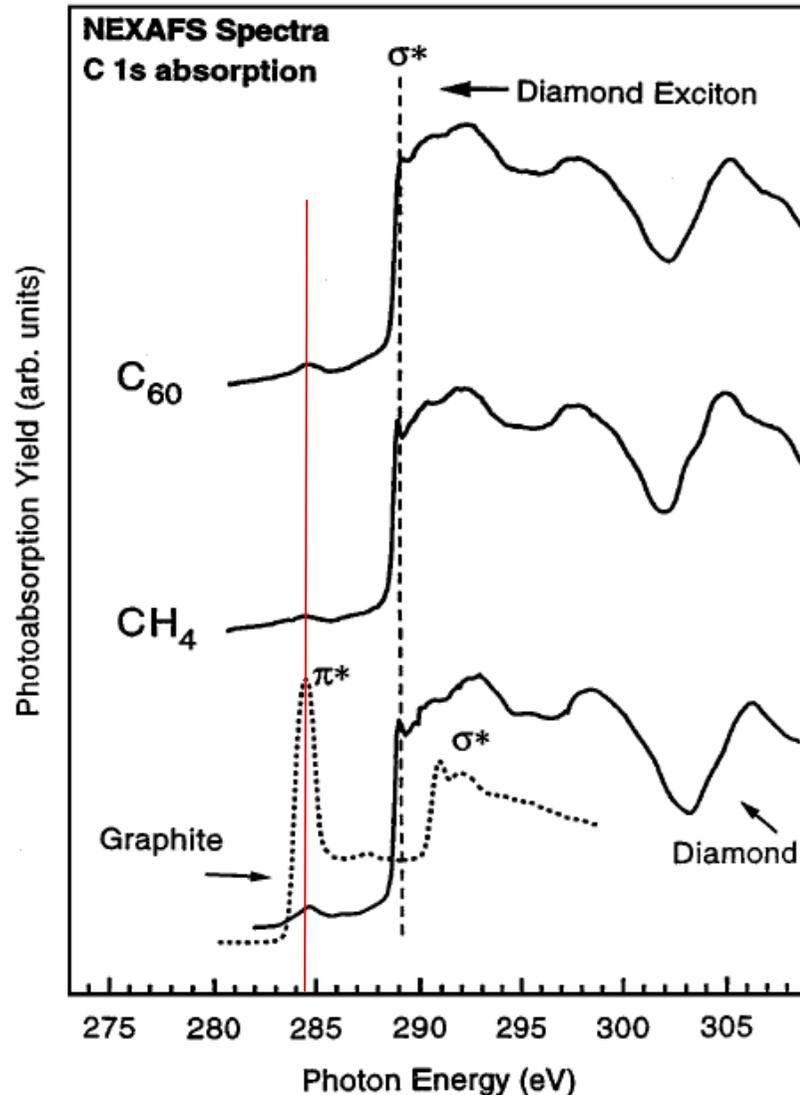
“pseudo“ NCD with perfect columns: grain boundaries only lateral (2D)

10nm diameter  $\Rightarrow 10^{12}/\text{cm}^3$



Kulisch et al. (2006)

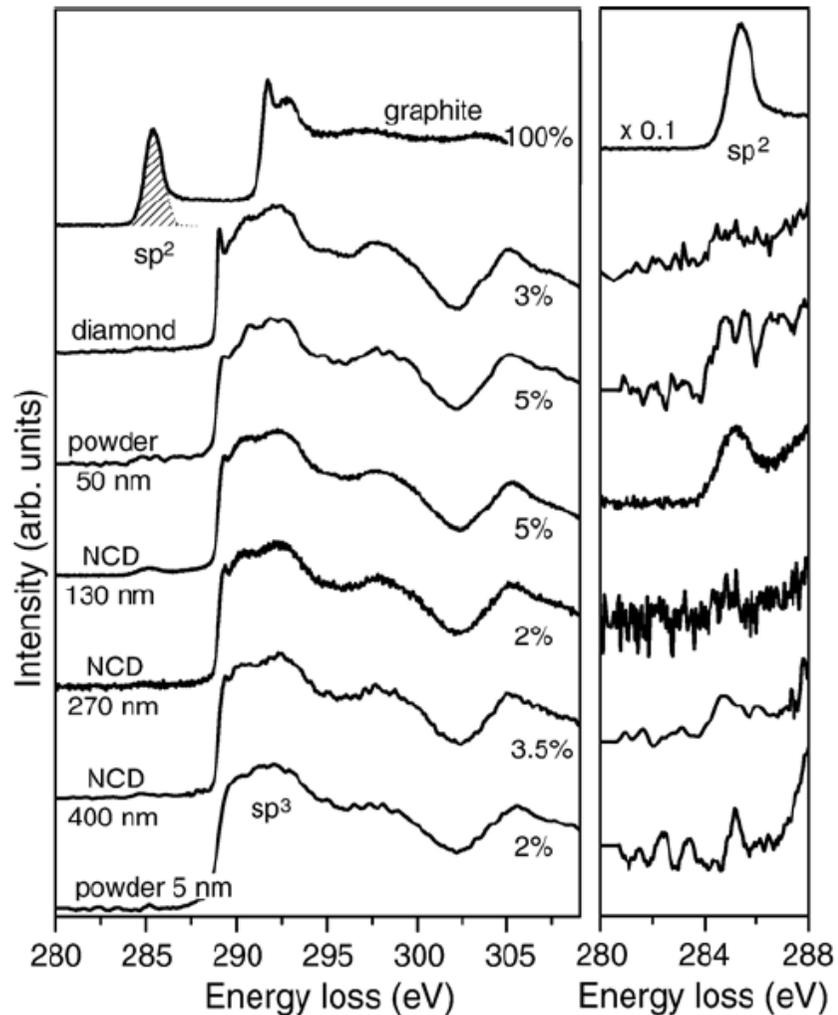
# Properties of UNCD films: $sp^2$ carbon



Gruen Annu. Rev. Mater. Sci 1999

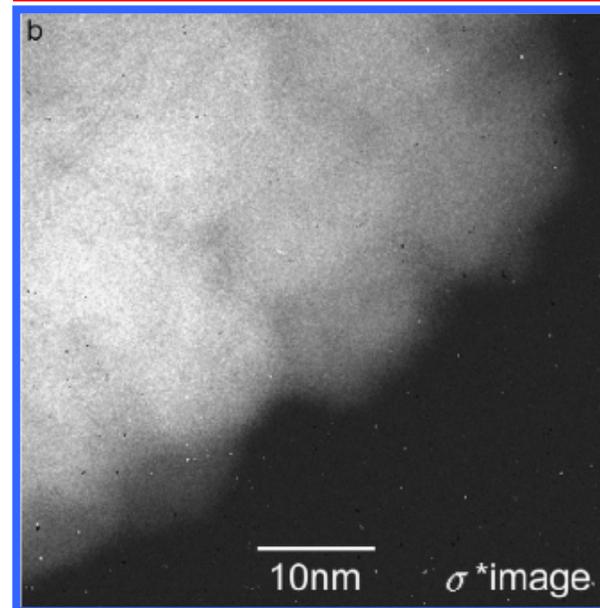
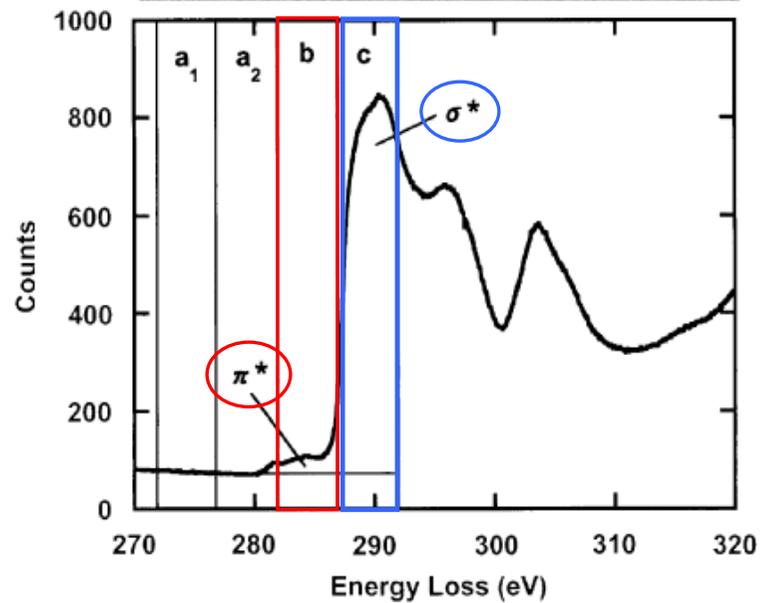
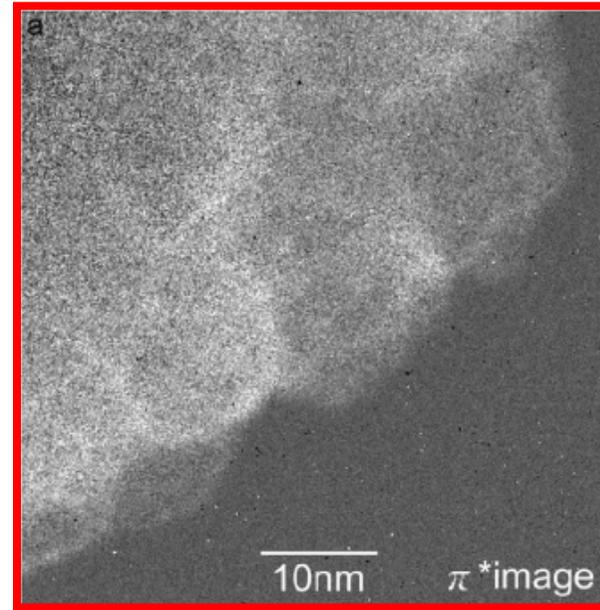
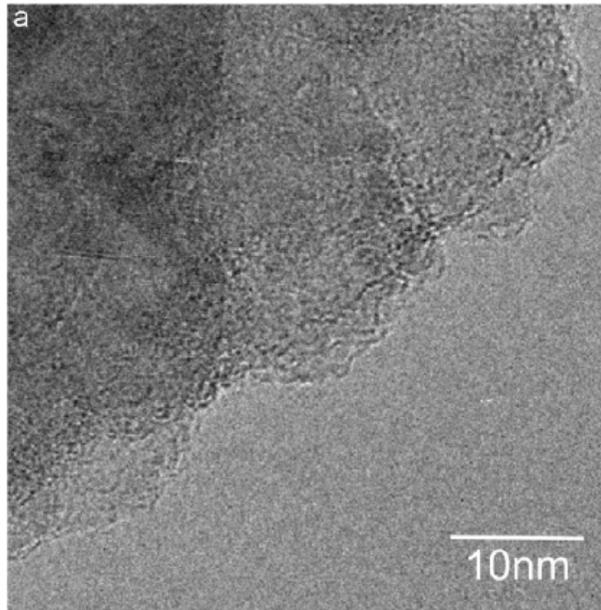
- NEXAFS to determine fraction of  $sp^2$  carbon:  
C1s absorption with clearly separated signal of  $sp^2$  and  $sp^3$  C
  - In this example: less than 5%  $sp^2$  bonded carbon
  - Most probably at the grain boundaries/boundary between grains and matrix
- ⇒ Influence of grain size on  $sp^2$  concentration

# Determination of $sp^2$ carbon: EELS

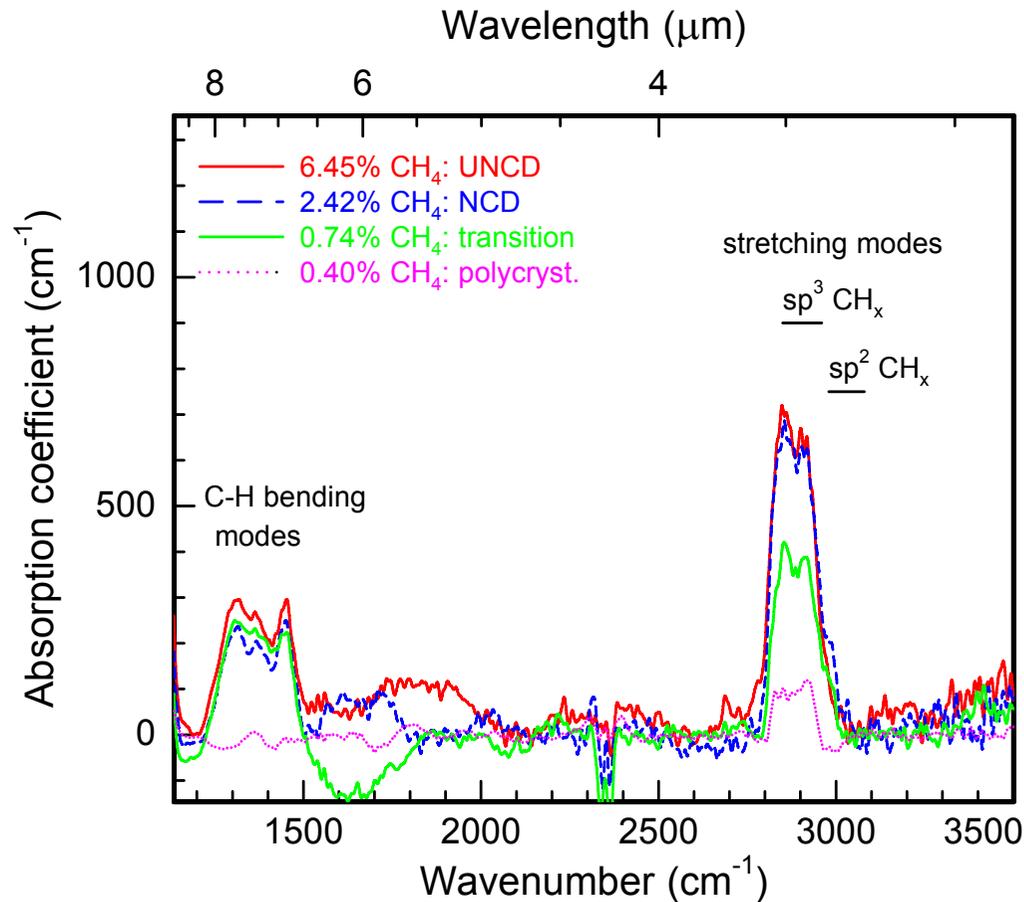


- Another possibility:  
Energy electron loss spectroscopy (EELS)
- XPS or TEM
- Advantage of TEM: mapping

# EELS at TEM: sp<sup>2</sup> carbon at grain boundaries



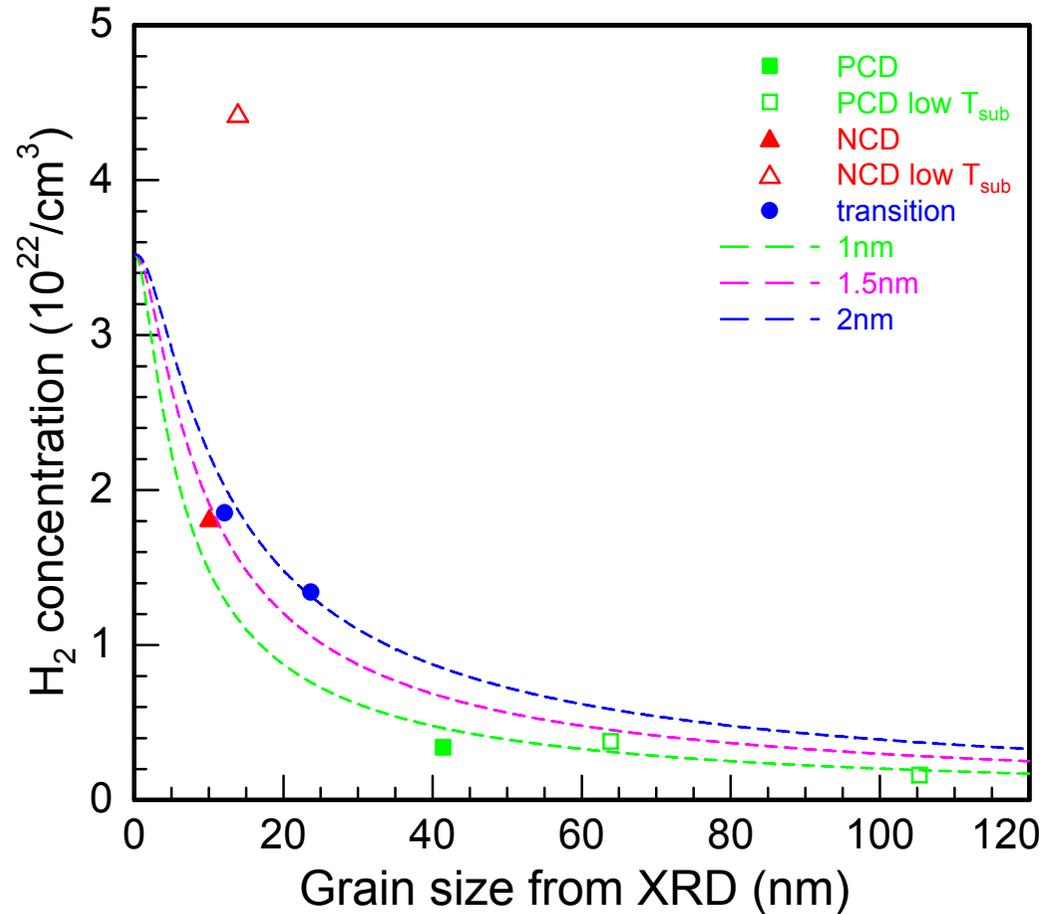
# H concentration: IR absorption



Sternschulte et al. Diamond 2006

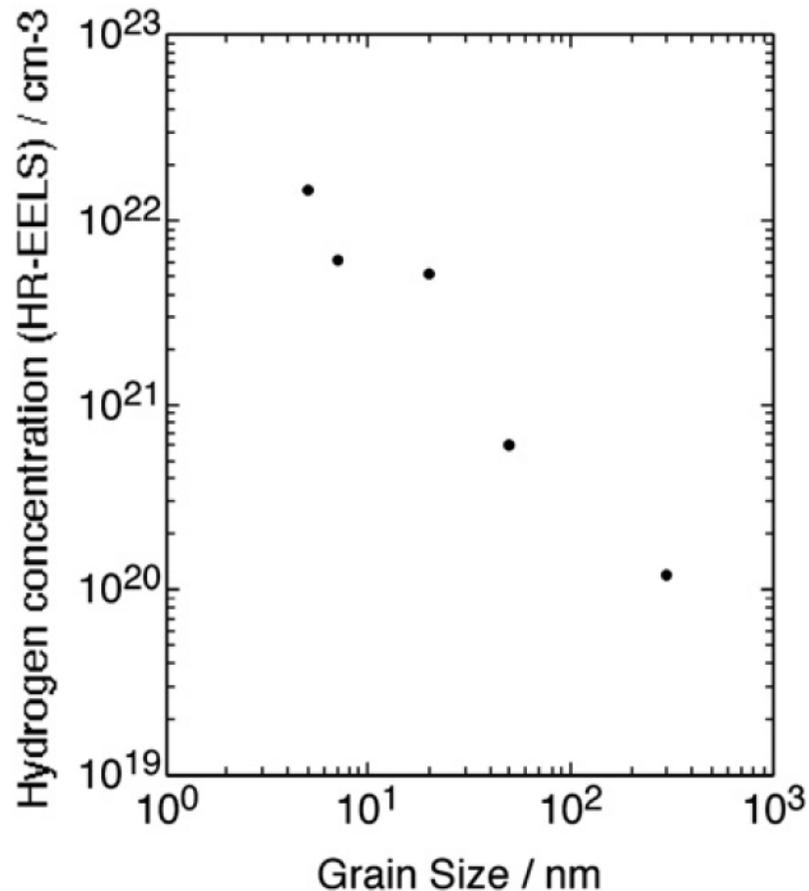
- IR absorption shows clear signal of C-H modes
- Measurement of bulk material

# H concentration in NCD films



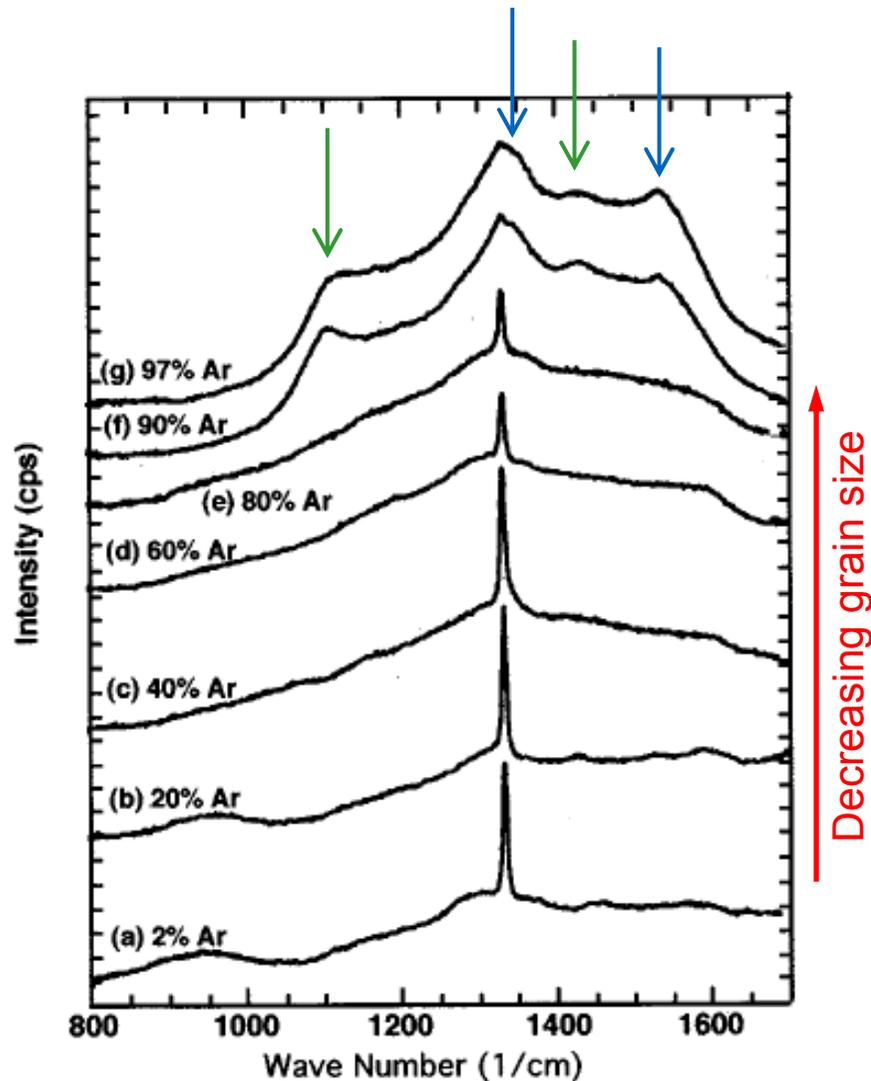
- H concentration scales with grain size  
⇒ H is incorporated in the grain boundaries

# H incorporation in UNCD films



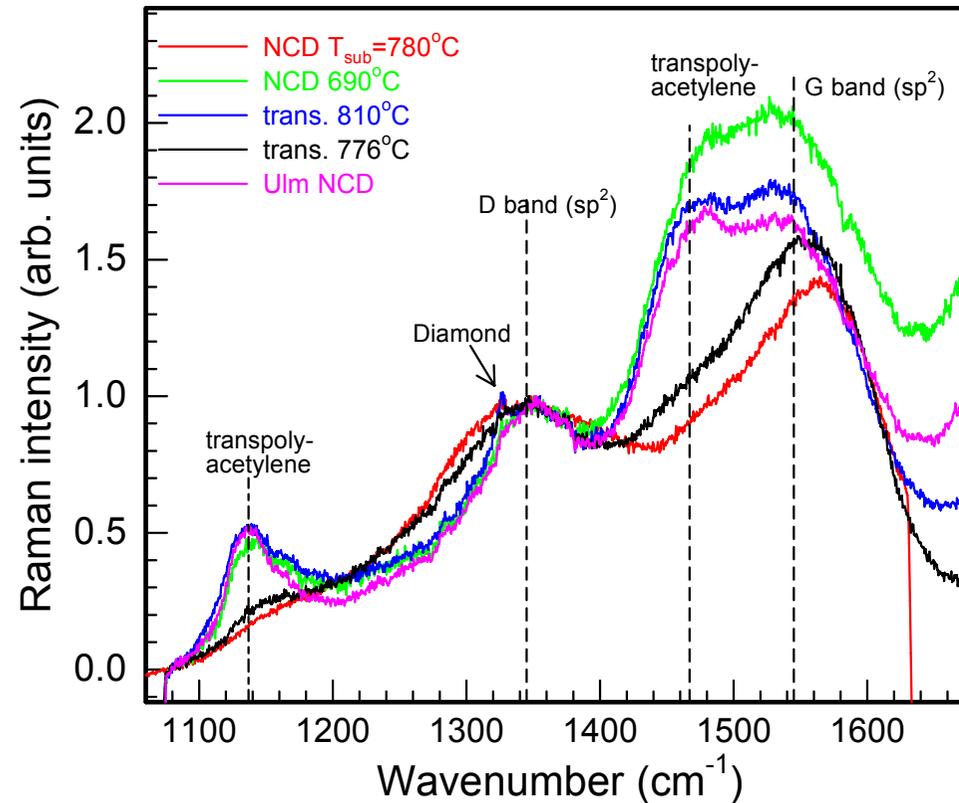
- High resolution electron loss spectroscopy (HREELS): inelastic scattering of electrons near the surface
  - ⇒ Excitation of C-C and C-H vibration modes
  - ⇒ Identification of H bonding: H-sp<sup>2</sup> C and H-sp<sup>3</sup> C
- H concentration calibrated with SIMS

# Optical properties: Raman



- With decreasing grain size:  
diamond Raman line at  $1333\text{cm}^{-1}$   
weaker and broadened
- Strong signal of **D** and **G band**  
i.e.  $\text{sp}^2$  C
- Diamond peak more pronounced  
with UV excitation
- New lines at  $1140\text{cm}^{-1}$  and  
 $1480\text{cm}^{-1}$ :  
trans-polyacetylene at grain  
boundaries

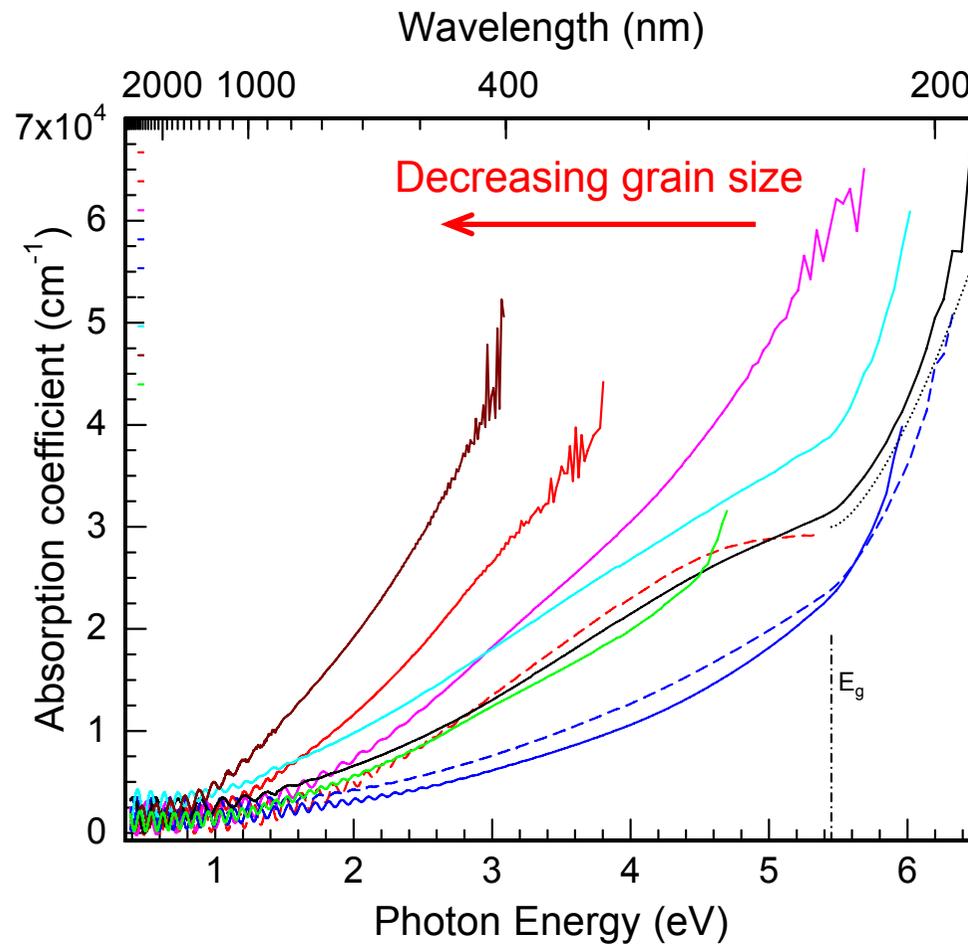
# Raman: influence of growth parameters



Sternschulte et al. Diamond 2007

- Signal of trans-polyacetylene influenced by growth conditions
- Annealing at 1200°C: trans-polyacetylene lines vanish

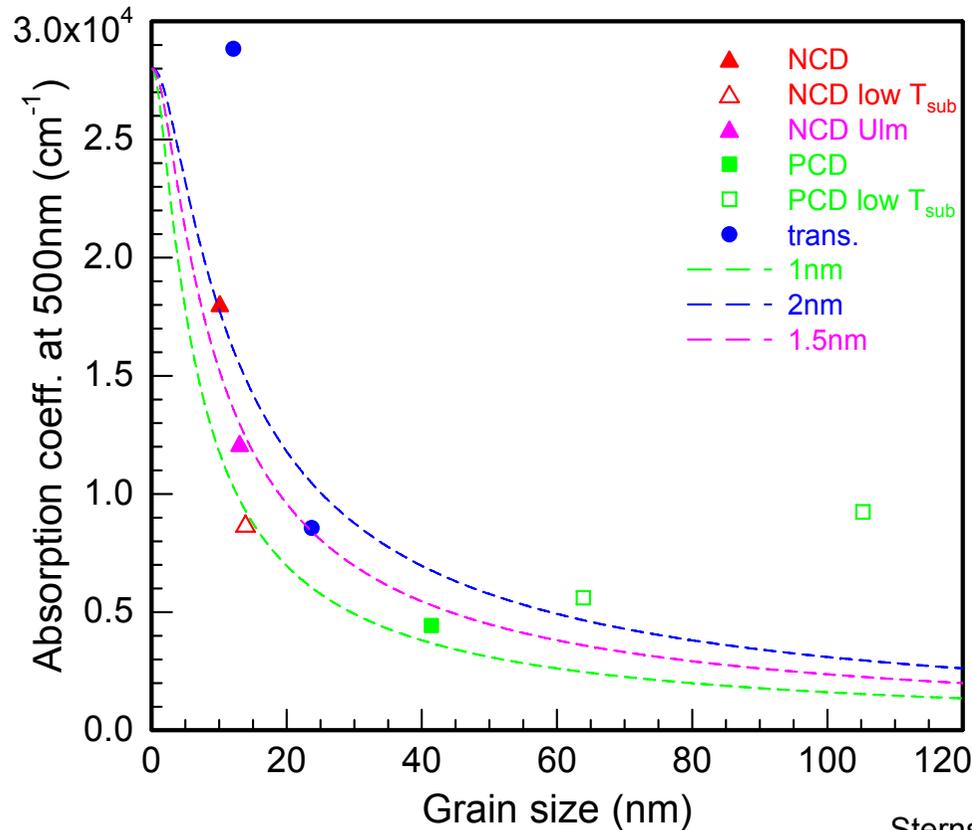
# Optical absorption UV-VIS



Sternschulte et al. Diamond 2007

- UNCD/NCD: strong absorption in the visible spectral range

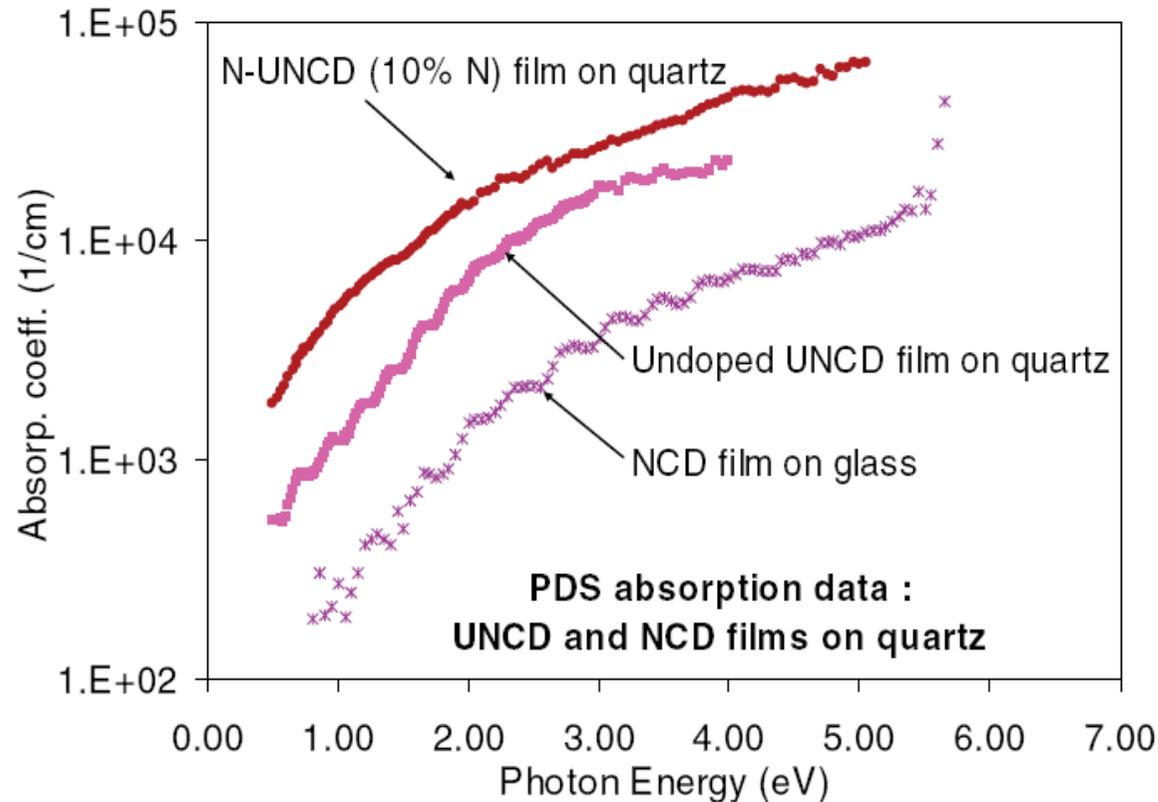
# UNCD: Optical absorption by matrix



Sternschulte et al. Diamond 2007

- Absorption depends strongly from grain size  
⇒ Absorption caused by grain boundary material

# Optical properties of UNCD/NCD and “pseudo” NCD



Williams et al. phys. stat. sol. (a) 2006

- “Pseudo” NCD: order of magnitudes lower number of grain boundaries  
⇒ Weaker absorption signal

# Electronic properties: doping of UNCD/NCD

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- Undoped UNCD/NCD: high electrical resistivity

⇒ Doping required to enhance electrical conductivity

- Doping of diamond

p-type doping:            Boron             $E_{AB} = 370\text{meV}$

n-type doping:            Phosphorus     $E_{DP} = 600\text{meV}$

                                 Nitrogen             $E_{DN} = 1700\text{meV}$

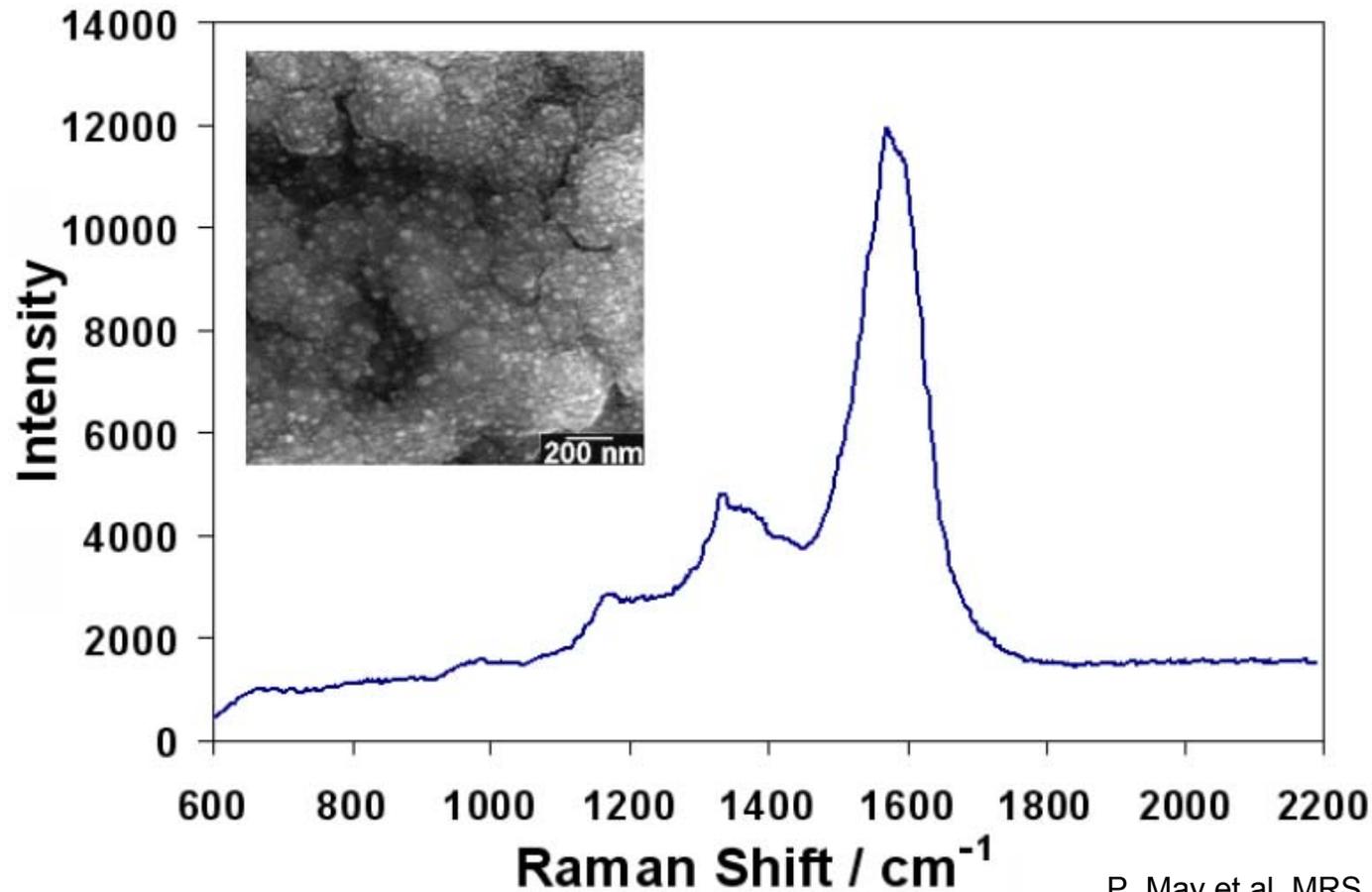
⇒ Doping of UNCD/NCD with similar approach

# UNCD/NCD: p-type doping with boron

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- Most literature about boron-doped NCD:  
“pseudo” NCD i.e. growth parameters as PCD
- Influence of boron addition during CVD deposition of UCND?

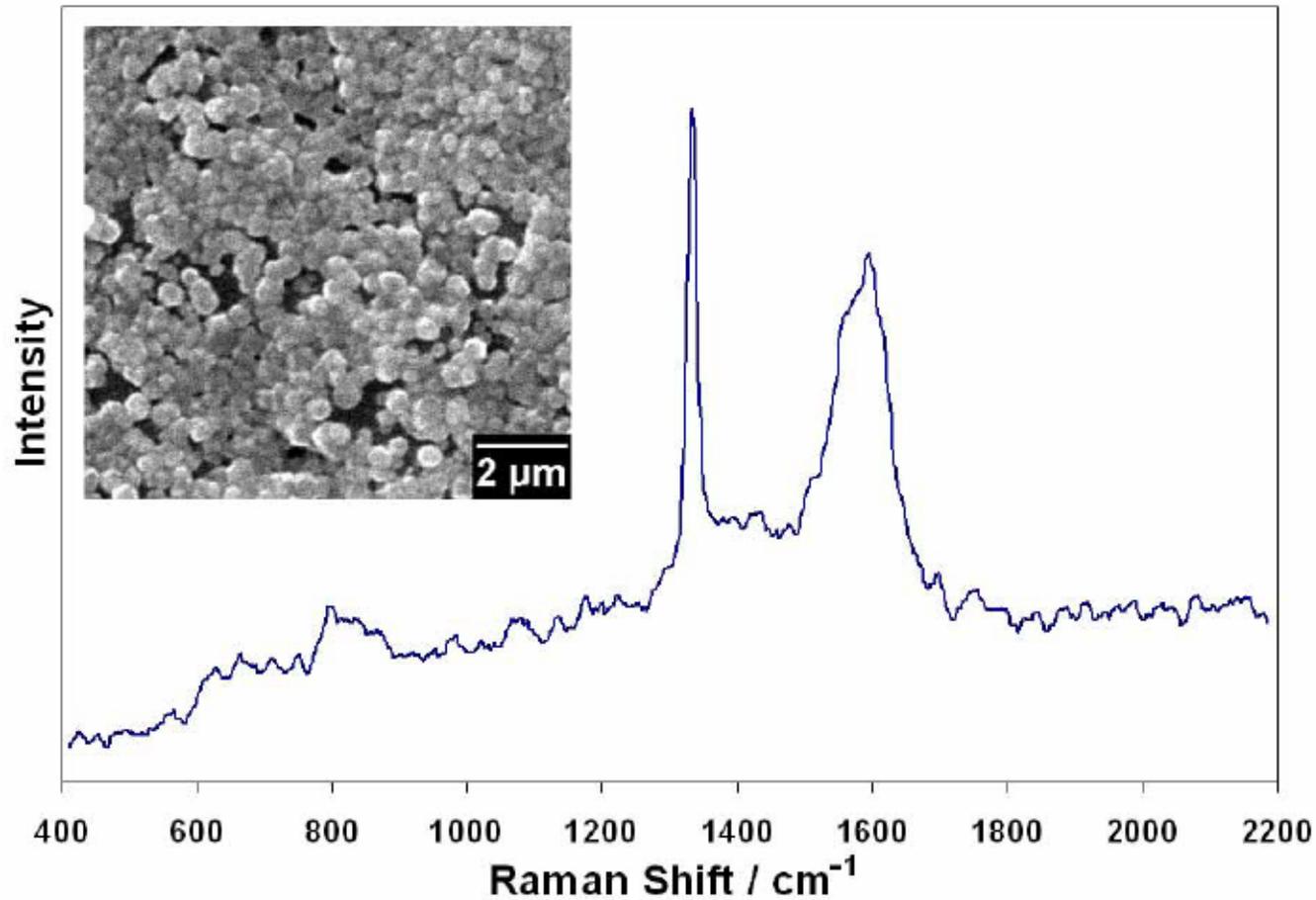
# UNCD deposition without boron addition



P. May et al. MRS Proc. 956 (2006)

- Deposition of UNCD with hot filament reactor and CH<sub>4</sub>/H<sub>2</sub>/Ar gas mixture with 0.5sccm CH<sub>4</sub>/50sccm H<sub>2</sub>/200sccm Ar

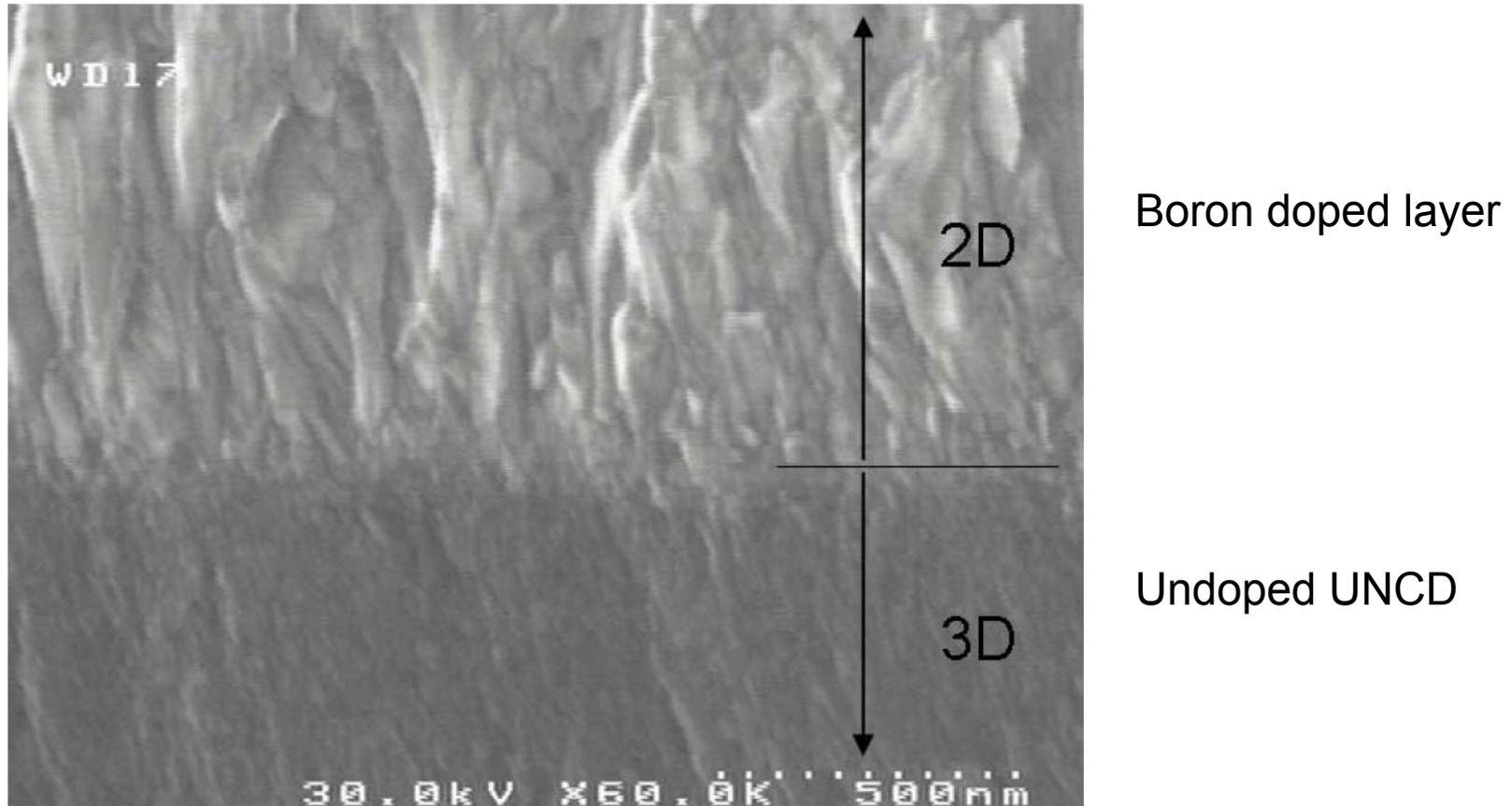
# UNCD deposition with boron addition



P. May et al. MRS Proc. 956 (2006)

- Addition of B<sub>2</sub>H<sub>6</sub> (300ppm with respect to CH<sub>4</sub>)  
⇒ Change of morphology and growth mode!

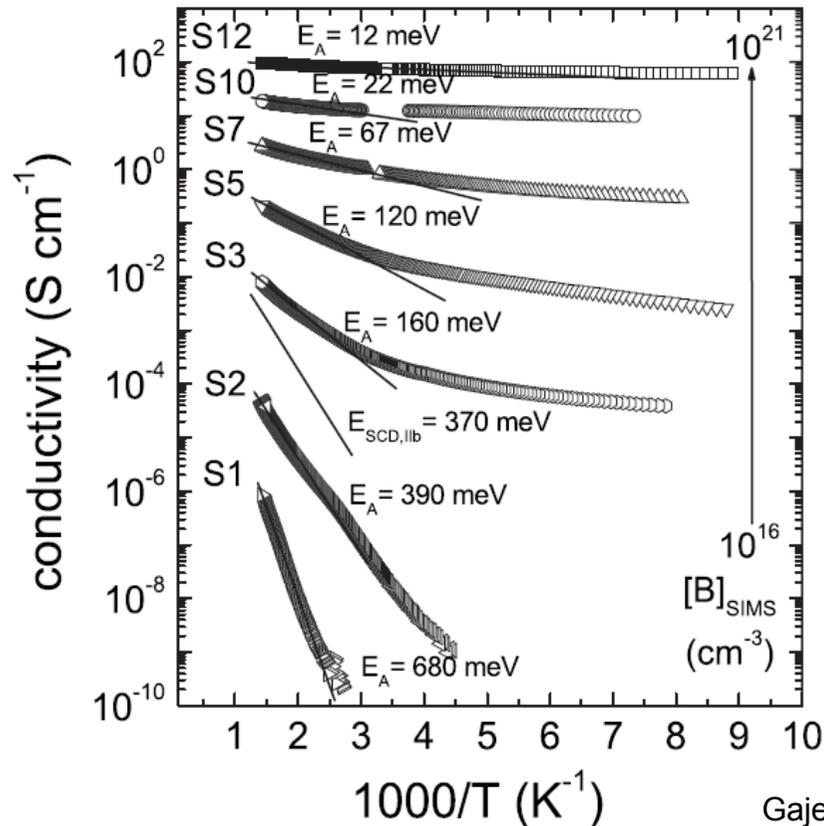
# Influence of boron addition on UNCD growth



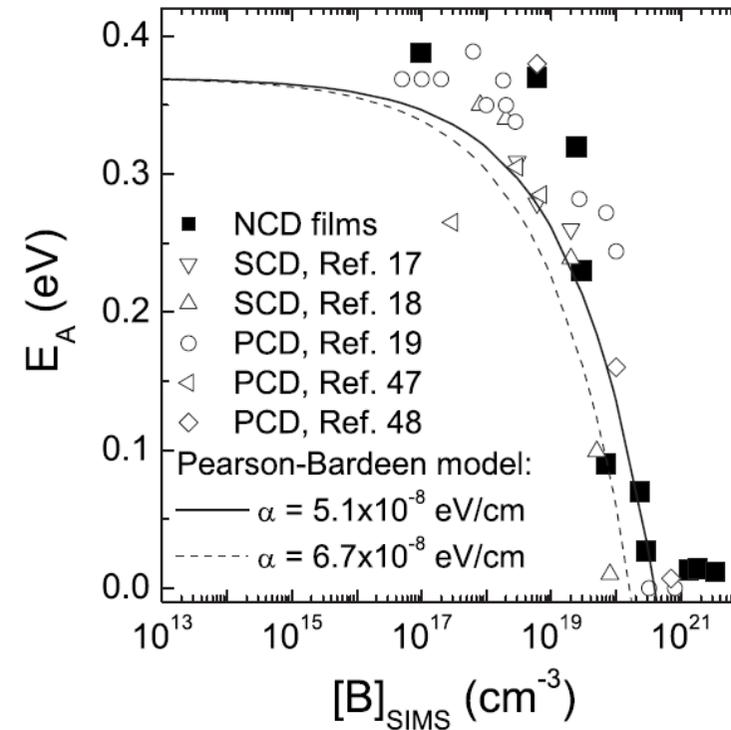
M. Dipalo, Dissertation Uni Ulm 2008

- Reduced secondary nucleation rate  
⇒ Change to columnar growth behaviour

# Boron doped "pseudo" NCD

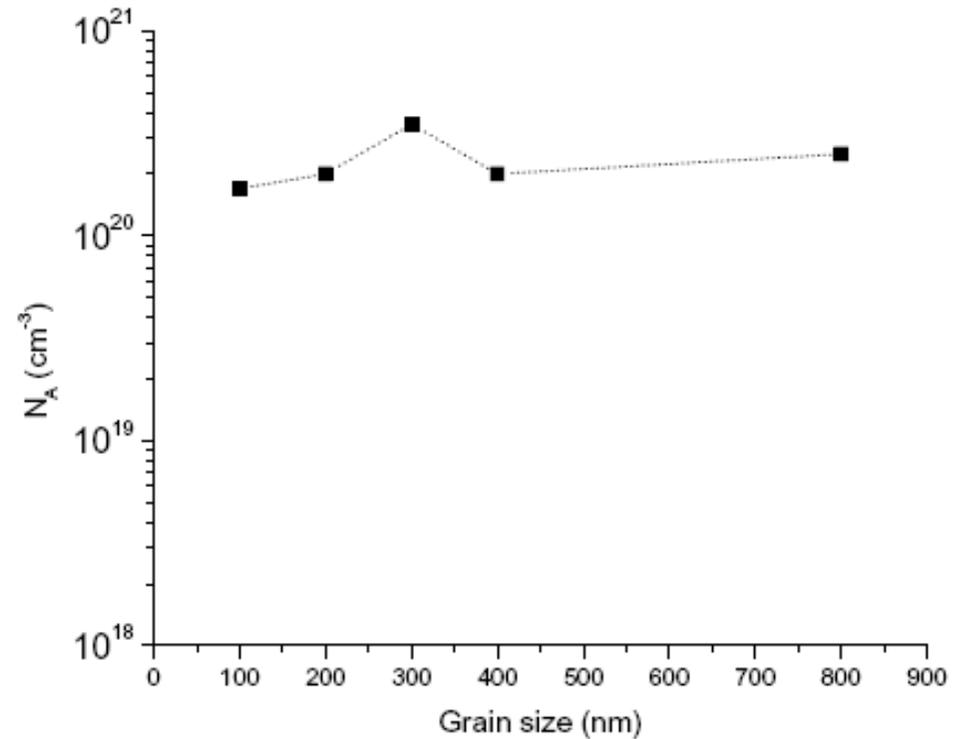
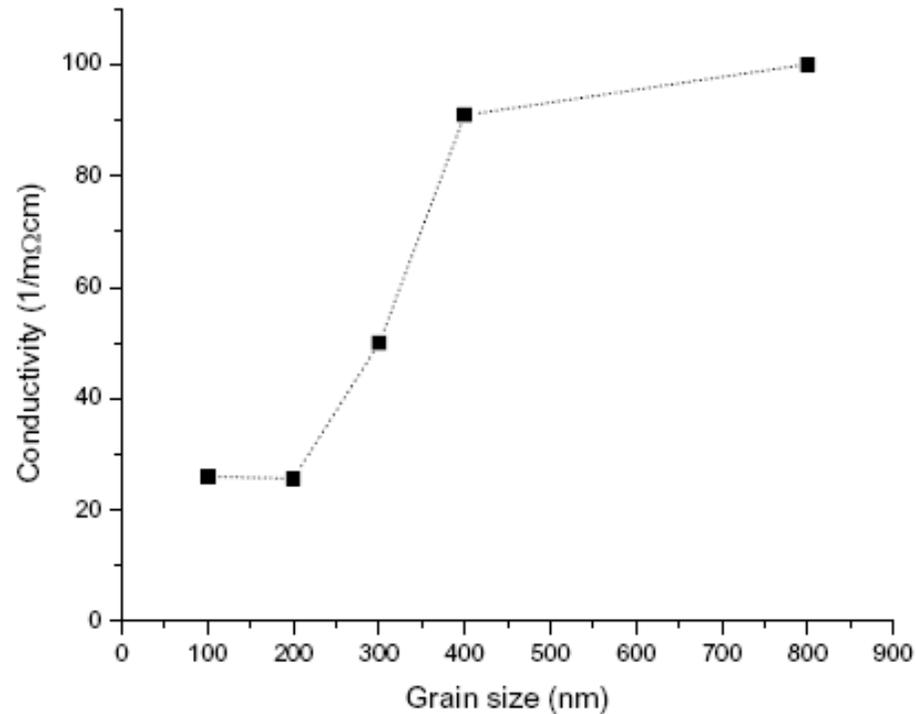


Gajewski et al. Phys Rev B 2009



- Doping behaviour comparable to polycrystalline diamond
- Metallic doped "pseudo" NCD:  
superconductive behaviour observable with  $T_C = 1.7\text{K}$

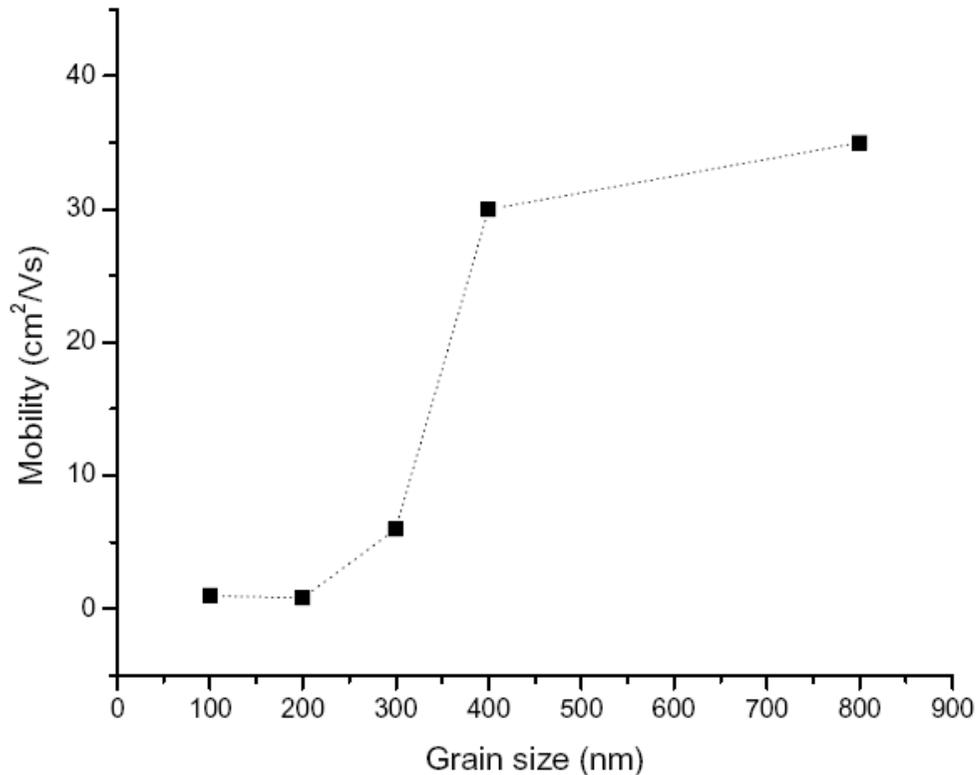
# Electrical properties of boron doped NCD: influence of grain size



M. Dipalo, PhD thesis, Universität Ulm 2008

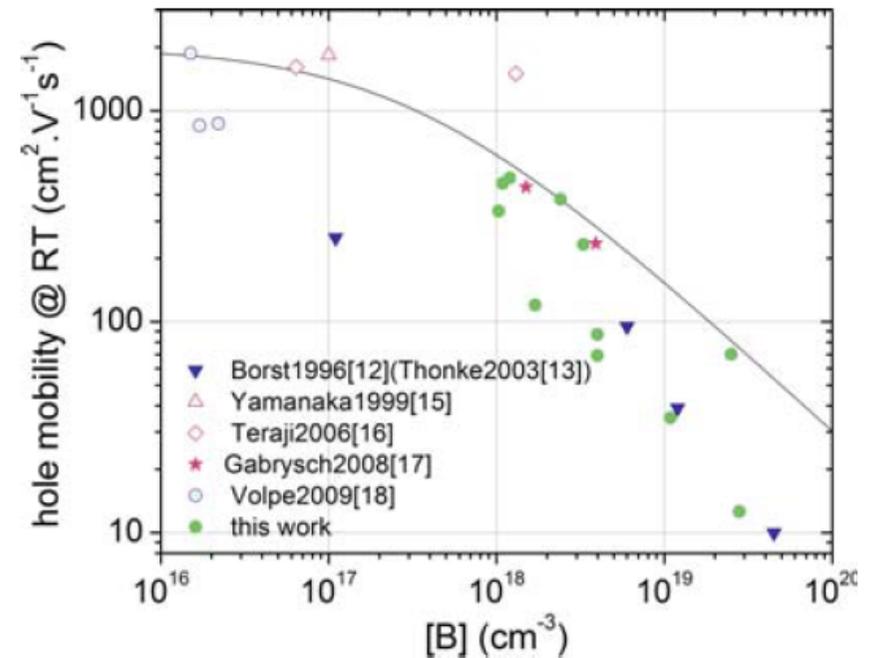
- Conductivity is strongly dependent from grain size

# Influence of grain size on mobility



M. Dipalo, PhD thesis, Universität Ulm 2008

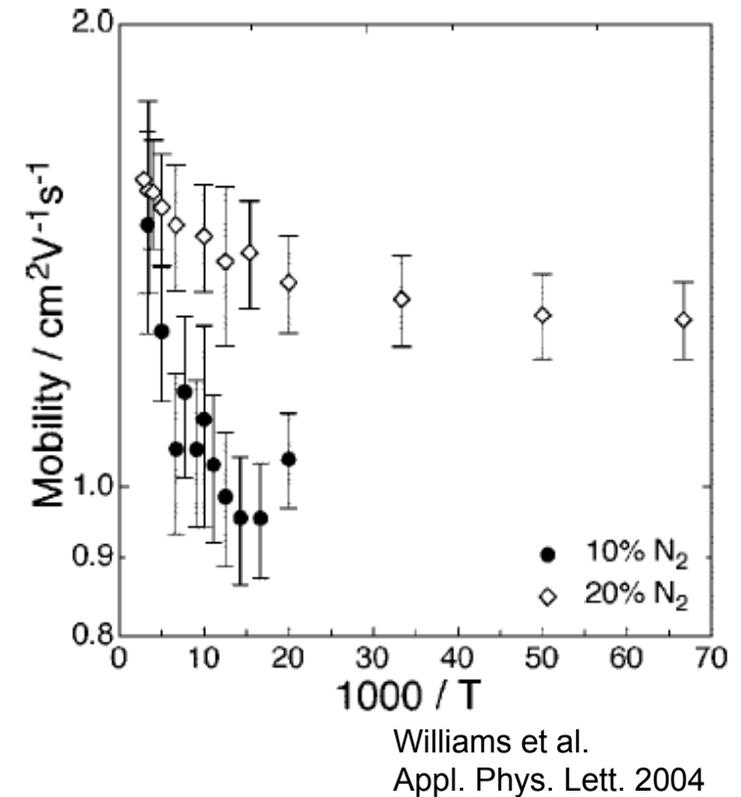
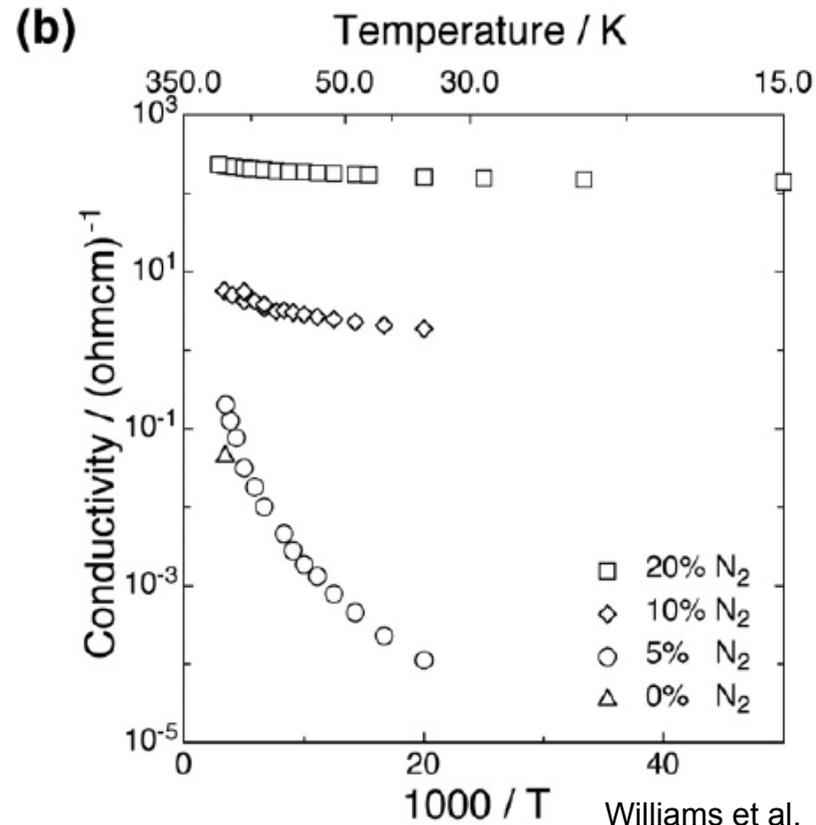
## Mobility of B-doped monocrystalline diamond



Barjon et al. phys. stat. sol. RRL2009

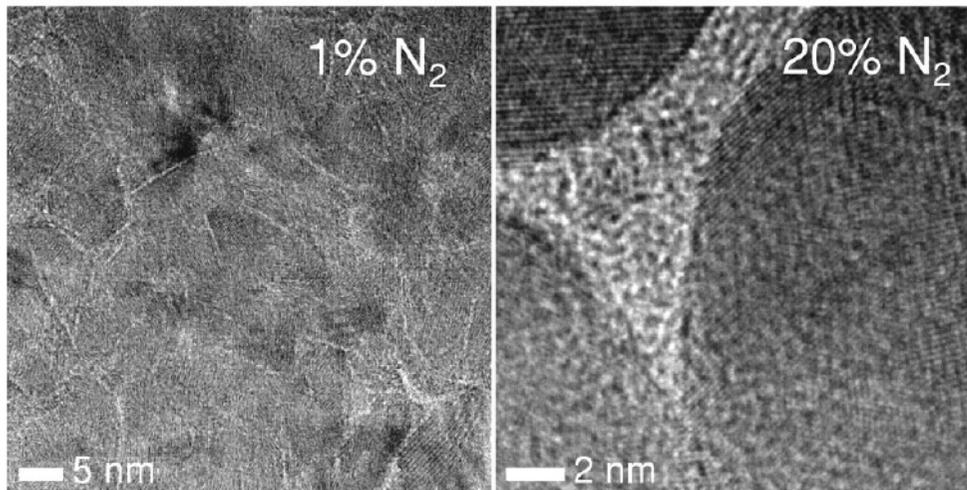
- Hole mobility drops down with decreasing grain size

# n-type doping of UNCD with Nitrogen

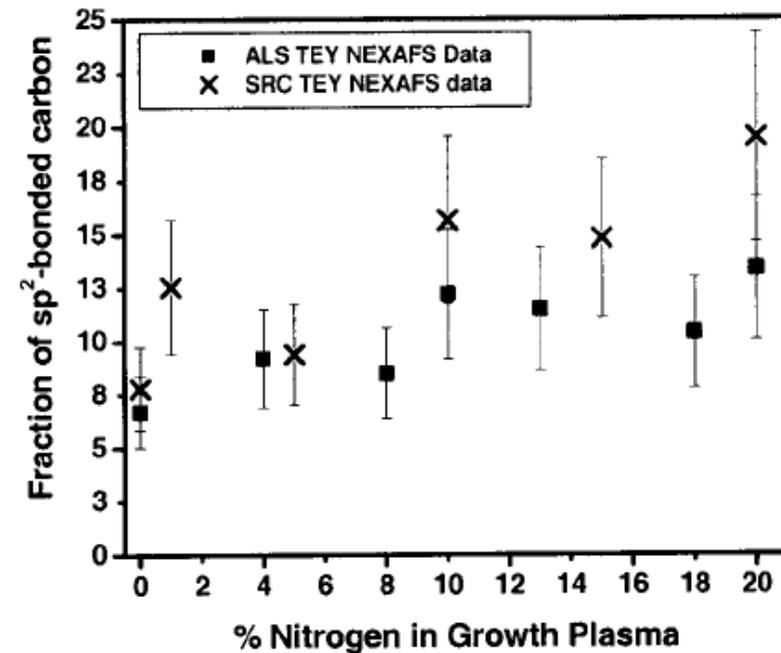


- n-type conductivity is observable
- Low activation energies of 10meV

# Nitrogen doped UNCD



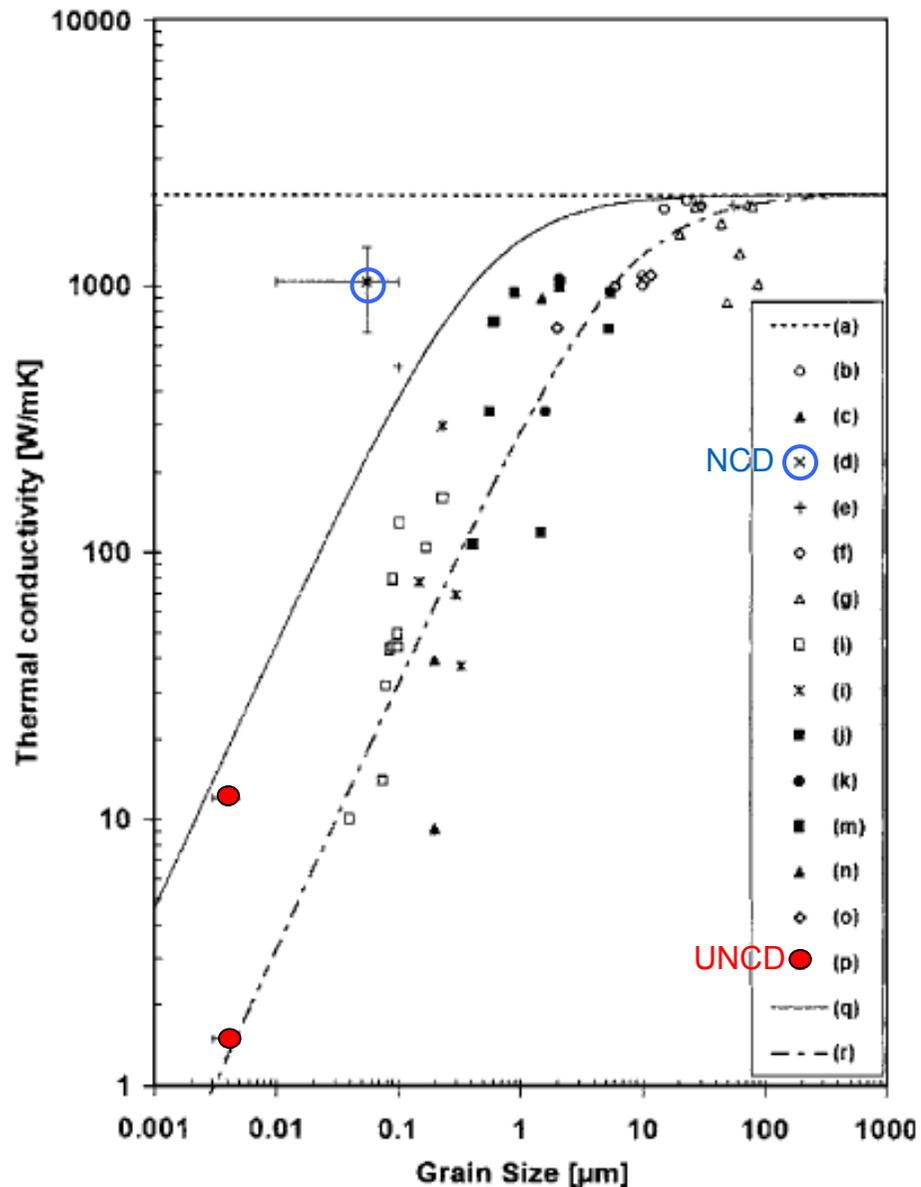
Bhattacharyya et al. Appl Phys. Lett. 2001



Birrell et al. J. Applied Phys. 2003

- By Nitrogen addition: larger diamond grains  
increased grain boundary width  
slightly increased sp<sup>2</sup> C concentration
- “Grain boundary” doping: modification of the matrix by nitrogen  
similar to DLC but with much higher mobility

# Thermal properties



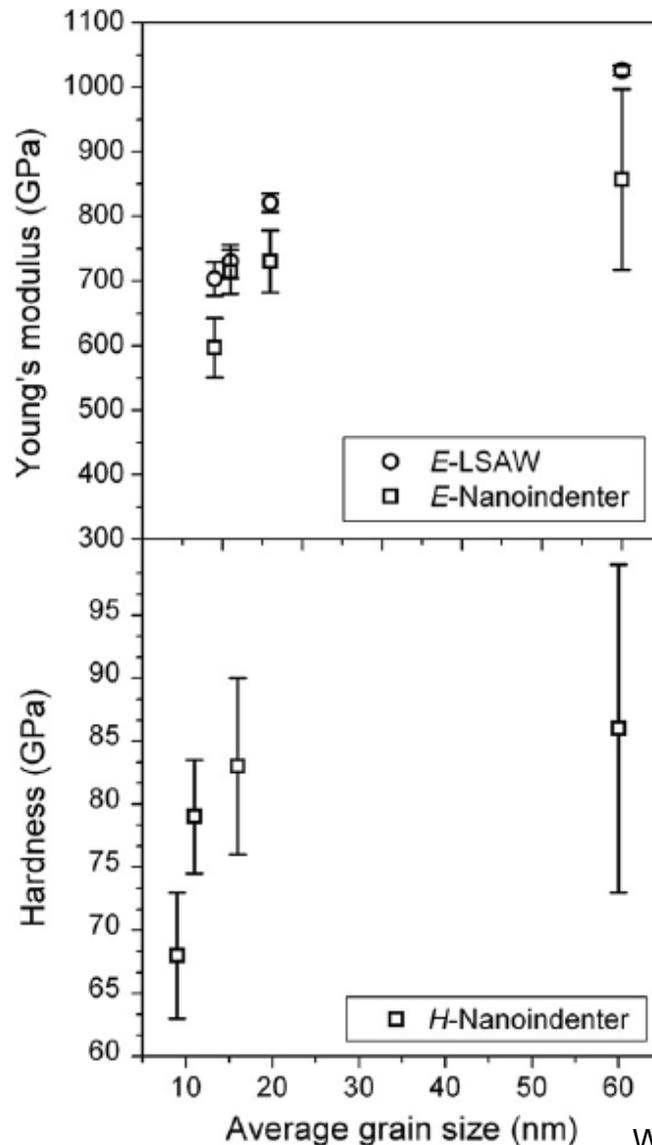
- Thermal conductivity decreases with smaller grain size

⇒ Thermal properties of UNCD rather poor

But: very smooth surface can be advantageous

⇒ Thermal transport of “pseudo” NCD much better

# Mechanical properties



- Young modulus depends on grain size
  - UNCD with 10nm grains: reduction of Young modulus by 30%
  - For comparison:
    - Si: 130GPa
    - SiC: 450GPa
- ⇒ UNCD ideal for MEMS

# Summary

- Ultra nanocrystalline diamond films:
    - very smooth diamond films
    - “homogeneous” isotropic material
  - Optical properties dominated by matrix:
    - strong absorption in the visible spectral range
  - Electronic properties:
    - n-type doping of UNCD by modification of matrix  $\Rightarrow$  n-type possible!
    - p-type doping of NCD: comparable to diamond but low mobility
  - Mechanical properties:
    - influence of grain size on Young modulus
    - but much higher Young modulus compared to other material
- $\Rightarrow$  It depends on the application if UNCD is the material of choice!